

**Supporting Information**

**One-step hydrothermal growth of porous nickel manganese layered double hydroxide nanosheets film towards efficient visible-light modulation**

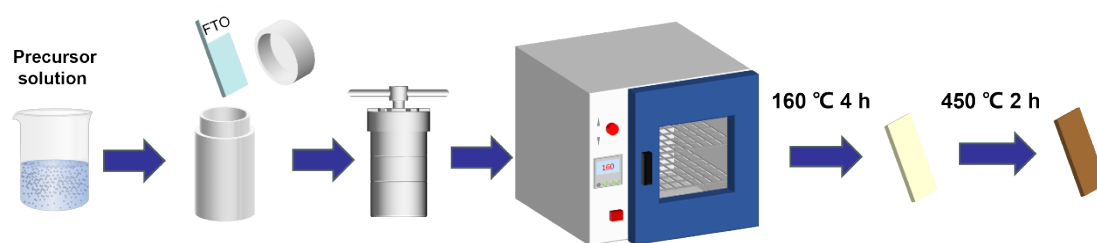
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## Supplementary Figures



**Fig. S1.** Schematic diagram for the hydrothermal preparation process of NiMn-LDH film and subsequent annealing process.

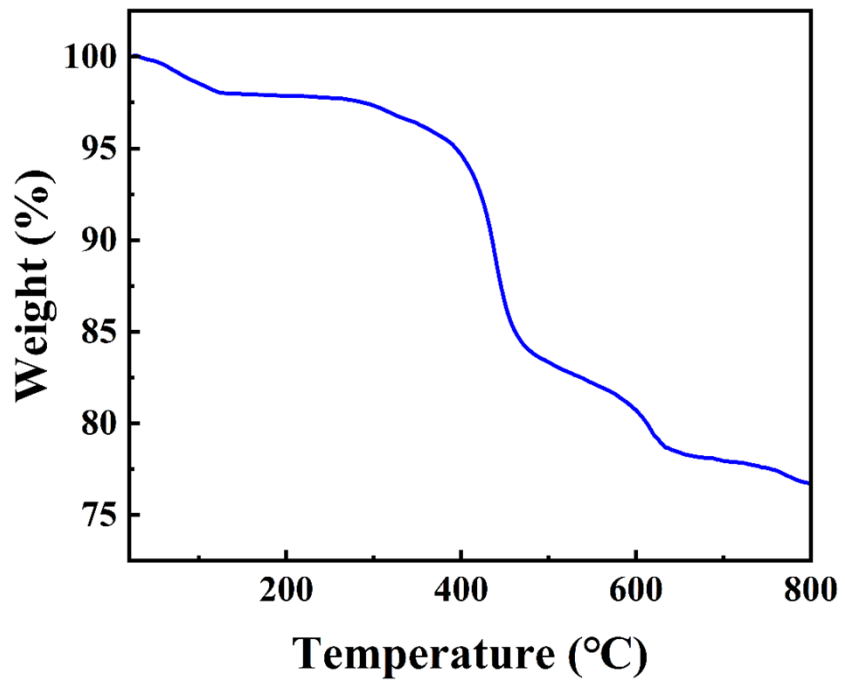


Fig. S2. TG curves of the NiMn-LDH powders.

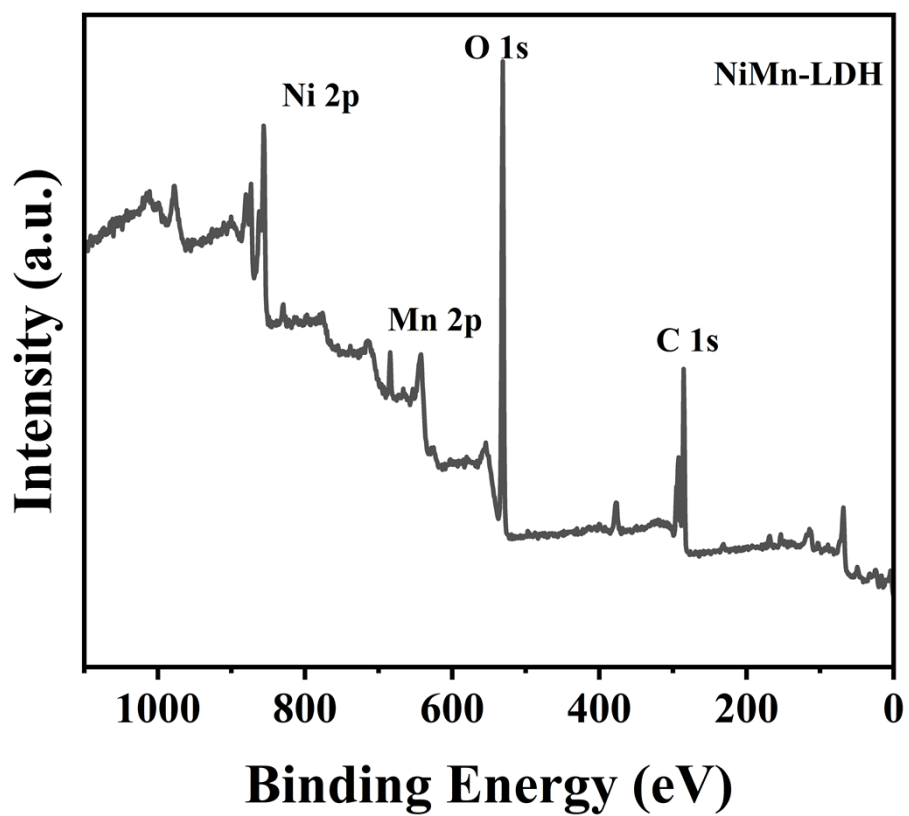
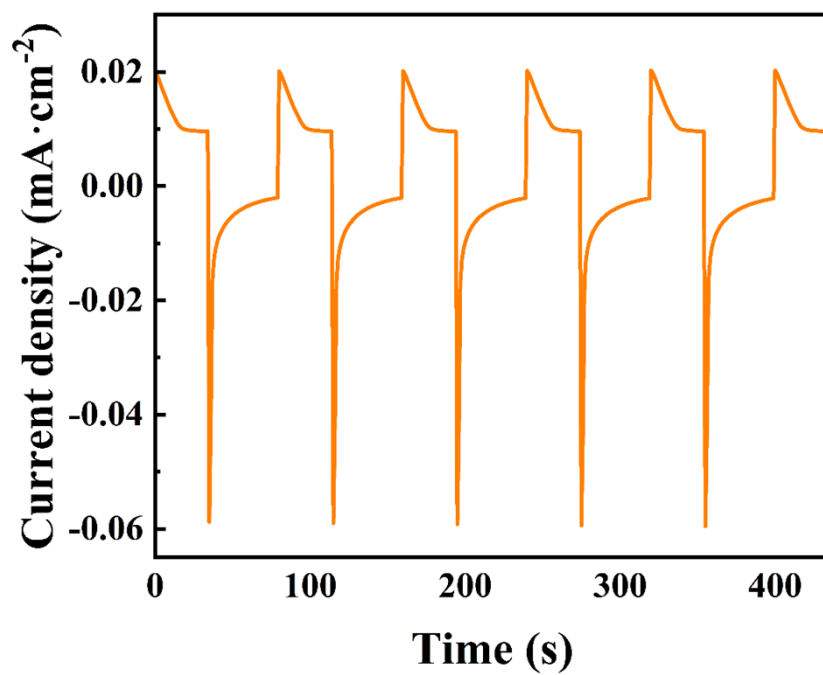
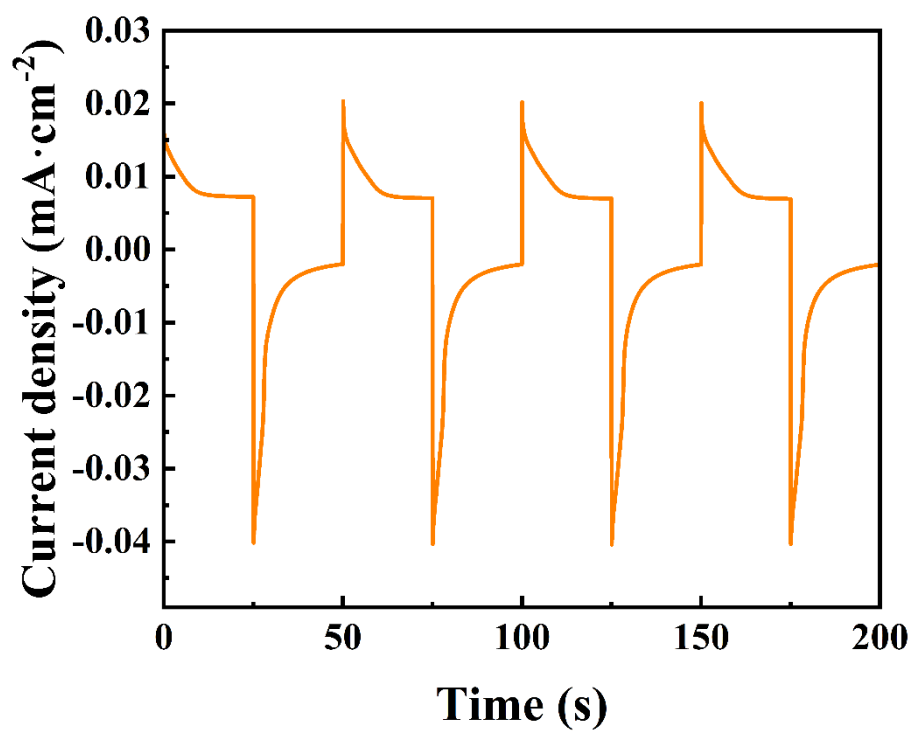


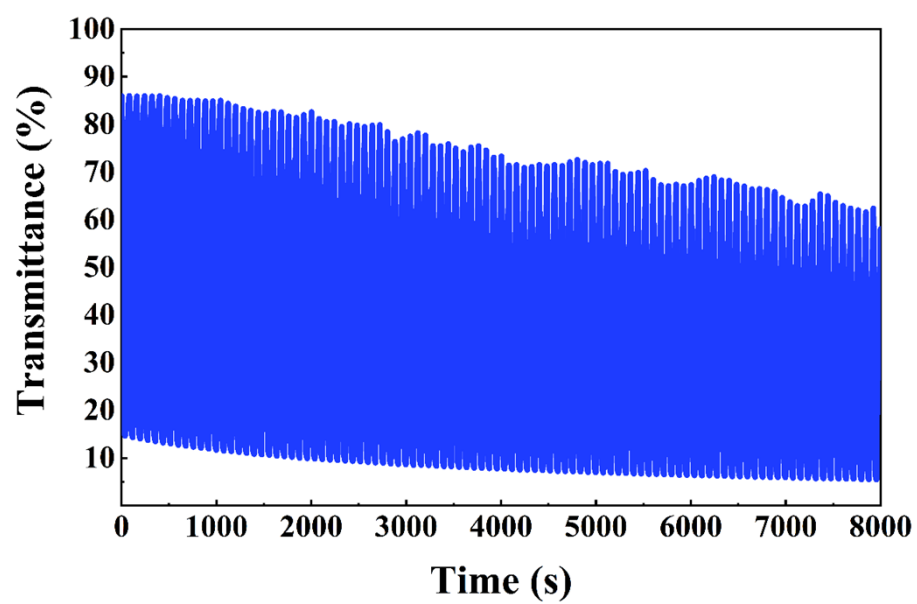
Fig. S3. The XPS survey spectrum of the as-grown NiMn-LDH film.



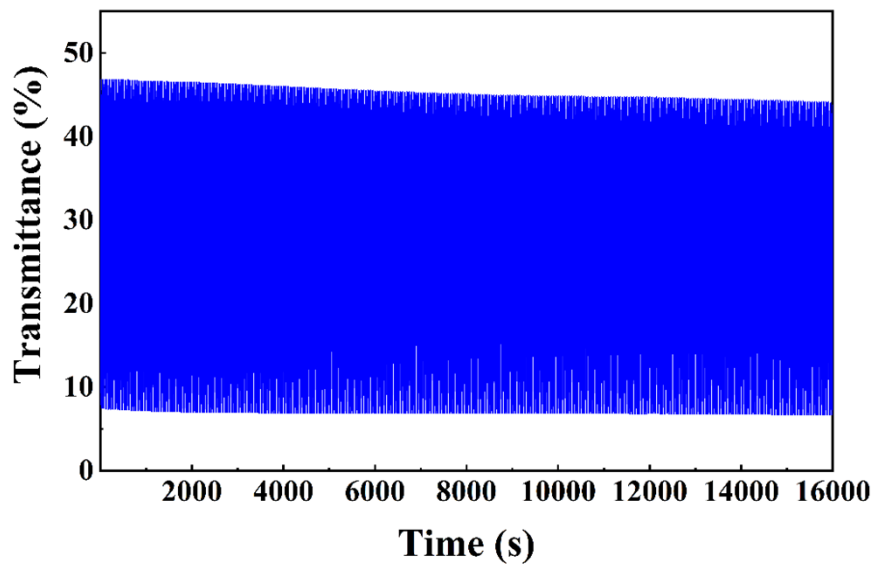
**Fig. S4.** Time-current curves of the NiMn-LDH film measured at -1.2 V for 45 s and 1 V for 35 s.



**Fig. S5.** Time-current curves of the Ni<sub>6</sub>MnO<sub>8</sub> film measured at -1.2 V for 25 s and 1 V for 25 s.



**Fig. S6.** Cycle performance of the NiMn-LDH film recorded at a wavelength of 550 nm.



**Fig. S7.** Cycle performance of the Ni<sub>6</sub>MnO<sub>8</sub> film recorded at a wavelength of 550 nm.



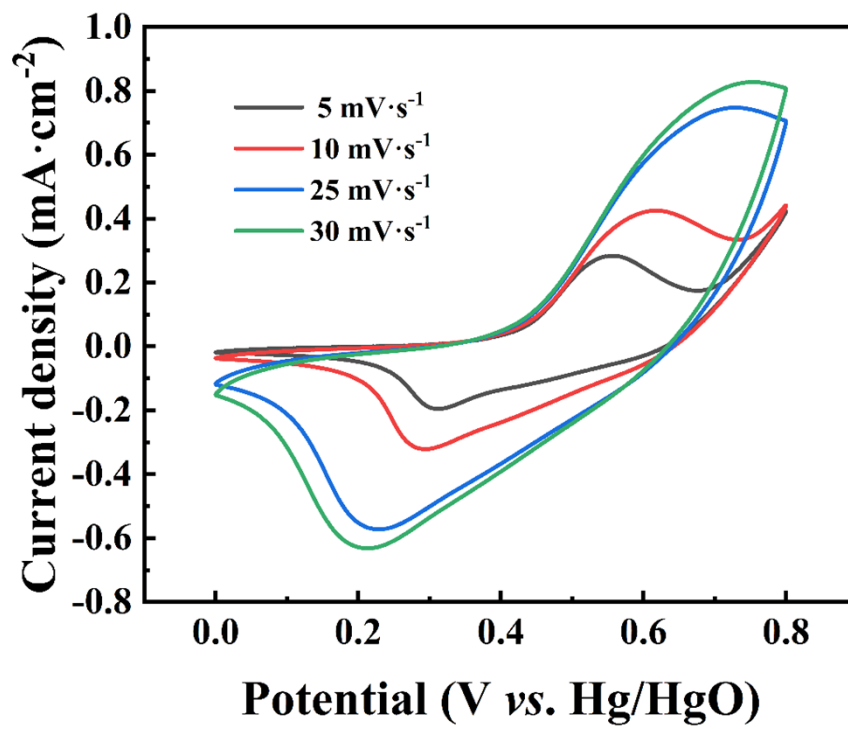


Fig. S8. CV curves of the NiMn-LDH film at different scan rates.

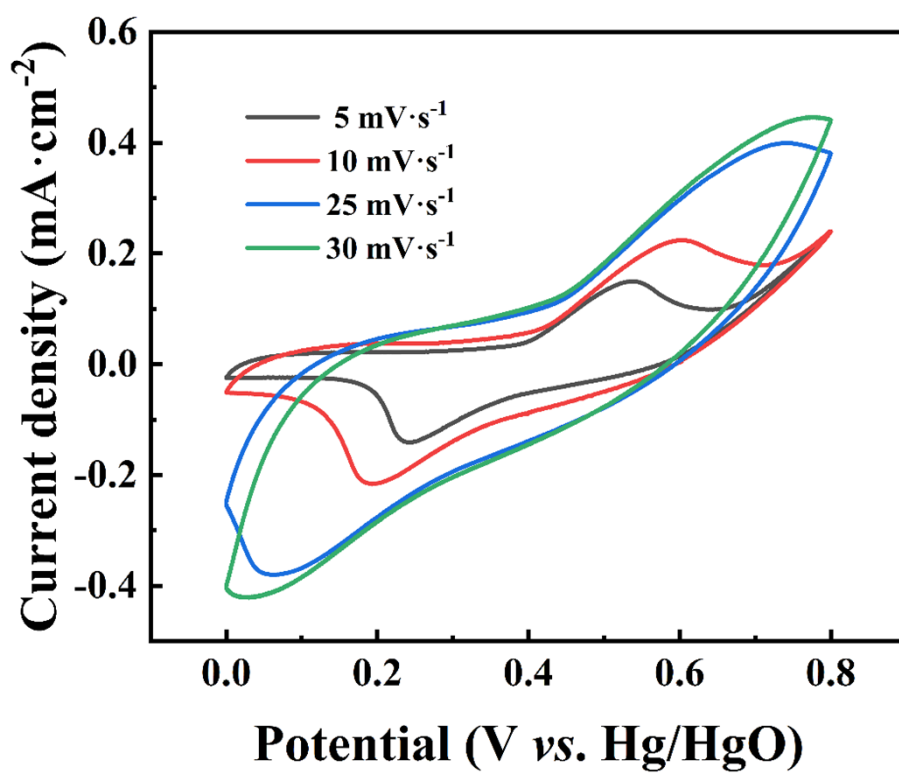
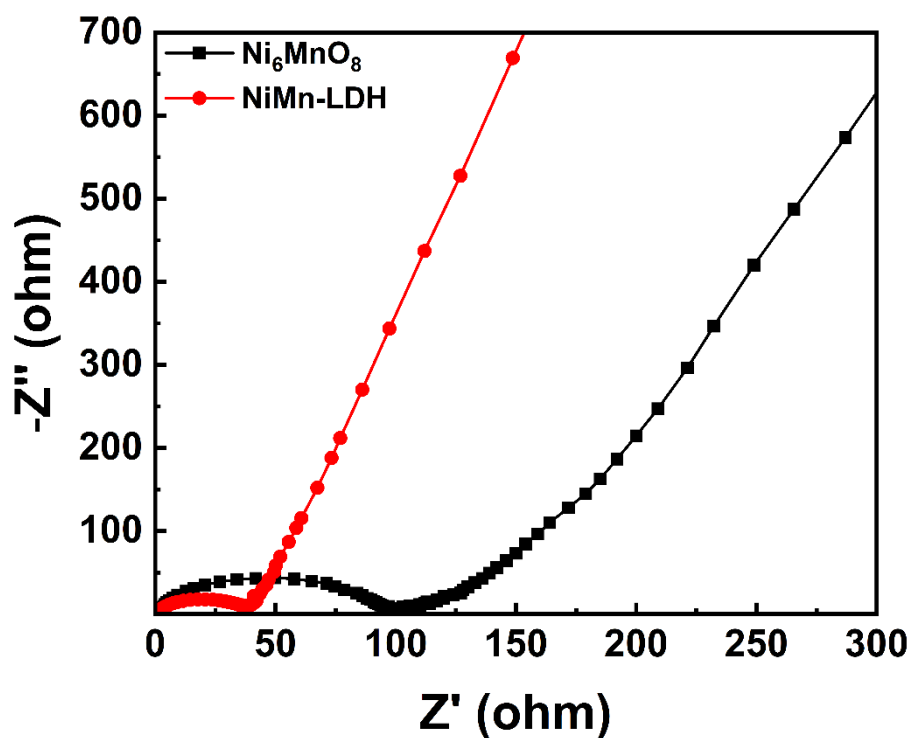


Fig. S9. CV curves of the  $\text{Ni}_6\text{MnO}_8$  film at different scan rates.



**Fig. S10.** EIS curves of (a) the NiMn-LDH film and (b) Ni<sub>6</sub>MnO<sub>8</sub> film.

Electrochemical impedance spectroscopy (EIS) was conducted to estimate the conductivity of the as-prepared film electrodes. Fig. S10 shows the resulting Nyquist plots of NiMn-LDH and Ni<sub>6</sub>MnO<sub>8</sub> film electrodes. The EIS curves of both electrodes consist of a straight line and a semicircle. The typical semicircle in the high-frequency region is attributed to the charge transfer resistance ( $R_{ct}$ ) caused by a faradic reaction that occurred at the active material surface.<sup>1,2</sup> Accordingly, the calculated  $R_{ct}$  for the NiMn-LDH and Ni<sub>6</sub>MnO<sub>8</sub> film electrodes are 19.8  $\Omega$  and 49.1  $\Omega$ , respectively.

## Supplementary Tables

**Table S1.** Microstructural parameters of different samples

Samples	Average crystallite size (D) nm	Dislocation density ( $\delta \times 10^{15}$ ) m <sup>-2</sup>	Strain ( $\epsilon \times 10^{-2}$ ) nm <sup>-2</sup>
NiMn-LDH	22.6	0.0021	0.42
Ni <sub>6</sub> MnO <sub>8</sub>	9.9	0.0037	0.76

“Various microstructural parameters are calculated from the XRD data and  $2\theta$  values of the diffraction peaks. The average crystallite sizes of the two samples are calculated by using Sherrer’s equation as follows:

$$(D) = \frac{0.9\lambda}{\beta \cos\theta}$$

where  $\lambda$  denotes the wavelength of Cu K $\alpha$  line (1.54 Å),  $\beta$  corresponds to full-width at half maximum, and  $\theta$  is the Bragg’s angle.<sup>6</sup> The lattice strain ( $\epsilon$ ) and dislocation density ( $\delta$ ) are also calculated by using the following equation:<sup>7,8</sup>

$$(\epsilon) = \frac{\beta \cot \theta}{4}$$

$$(\delta) = \frac{1}{D^2}$$

The calculated above parameters for NiMn-LDH and Ni<sub>6</sub>MnO<sub>8</sub> are summarized in Table S1.”

**Table S2.** Electrochromic properties of the different LDH films.

Film	$\Delta T$ (%)	$t_c$ (s)	$t_b$ (s)	$CE$ (cm <sup>2</sup> ·C <sup>-1</sup> )	Ref.
ZnO@Ni/Co-LDH	56.0% (550 nm)	0.7	2.7	—	[1]
NiAl-LDH	69.0% (400 nm)	45	45	30	[2]
PEDOT:PSS/LDH	32.0% (650 nm),	0.27	0.18	159	[3]
NiMn-LDH	68.5% (550 nm)	14.2	26.1	56.2	This work

## References

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